



An investigation into the surface termination and near-surface bulk doping of oxygen-terminated diamond with lithium at various annealing temperatures

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Abstract

An alternative method of doping and surface functionalization of diamond using a chemical route was explored. The interaction of Li with the surface and bulk of oxygen-terminated diamond was investigated using Angle-Resolved X-ray Photoemission Spectroscopy (ARXPS). A stable LiO₂ termination of diamond (100) surface and doping of near-surface diamond bulk was achieved up to an annealing temperature of 850 °C. The changes in interaction between the species involved (C, O, Li) and their stoichiometric ratios at the surface were investigated as a function of annealing temperature. This was done using ARXPS peak analysis.

Introduction

Our age has seen a huge demand on energy sources to provide for our day-to-day uses which we tend to fulfill by non-renewable sources. A way of decreasing so much burden on nonrenewable sources of energy is to produce materials with low work function. Using these materials, energy can be produced through thermionic emission where thermal energy makes the material emit electrons and hence provides us with devices that produce electric power. Diamond has been a focus of researchers as a potential material for creating low work function (thermionic emission) devices [1–4]. Tuning of the electrical properties of diamond by controlled doping of elements like oxygen, nitrogen, lithium, sodium, or boron [5, 6] has multiplied the interest in diamond research. Li-doped diamond films are believed to be a potential approach to create n-type semiconducting diamond with low resistivity and room temperature dopant activation. Theoretical studies predict the potential of Li to act as a shallow donor [7–9]. The energy gap between the Li donor

levels to conduction band of diamond is less than 0.3 eV [10], but effective Li doping is very difficult to obtain. One of the reasons for this is the low solubility of Li in diamond [11]. Researchers have previously attempted to incorporate Li into the diamond lattice by the processes of implantation [12, 13], diffusion [14, 15], and by gas phase in chemical vapor deposition (CVD) [16–18]. Zamir et al. [19] have demonstrated the possibility of doping diamond with higher concentrations of dopants Li and N using lithium nitride suspension and gaseous ammonia, respectively. Their method resulted in a higher concentration of both species than those reported by previous diffusion and ion implantation studies, with no lattice damage.

Besides tuning the conductivity of diamond, surface terminations can induce negative electron affinity (NEA) and hence provide ways to tune the work function (WF). It was found that hydrogen termination at the diamond surface induces an NEA of -1 eV for a number of crystallographic planes [20], this generates a small dipole on the diamond surface leading to a work function of 2.85–3.9 eV [20–22]. However, H-terminated diamond surfaces suffer from the phenomena of water adsorption, leading to charge transfer and unnecessary band bending [23, 24]. Along with the instability of H termination at higher temperatures (> 700 °C) [25], this restricts the use of H-terminated surface in thermionic applications. Cs–O-terminated diamond surface has been demonstrated to possess a work function of 1.5 eV, but Cs desorbs above a temperature of 400 °C [26]. Also, a work function

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of 1 eV is desirable for low-temperature thermionic applications which leads to a new interest of developing thermally stable, but highly polar surface structures. The study of low WF diamond has resulted in reports of many alternatives to hydrogen which can induce an NEA. This includes thin metal films [27], alkali-metal monolayers [28], alkali-halide films [29, 30], and alkali-oxide monolayers [26].

Oxygenation also plays a role in work function changes, as has been found in the cases of Si and Ge. Oxygen is also able to modify surface dipoles created by alkali-metal adsorption. In the case of diamond, the lightest alkali-metal, Li, on diamond surfaces has been observed to lower the work function of and at the same time form stronger bonds with the surface than the heavier alkali metals.

This has been demonstrated by O'Donnell [31] who performed the first ab initio calculations for Li adsorbed onto the C(100)–2×1 and C(100)–1×1:O surfaces. The results showed a large NEA and high binding energy per Li atom for the system consisting of a full monolayer of Li, adsorbed on a fully oxygenated Diamond (100) surface. These results indicate that the properties of Li adsorption on diamond generally agree with those of heavier alkali metals on silicon, diamond, and germanium. O'Donnell demonstrated the formation of a stable Li–O termination of diamond by physical vapor deposition of a monolayer of Li on the diamond surface which develops and exhibits NEA even at an elevated temperature of 800 °C [32].

In this work we are seeking an alternative method of introducing and coordinating Li with oxygen on the diamond surface. As mentioned earlier, the introduction of Li atoms into diamond lattice has been demonstrated [19], but here we are exploring the novel and facile chemical means to realize a more controlled approach of creating a stable –O–Li dipole. This will lead to NEA condition uniformity over the diamond surface. We also plan to study and visualize for the first time the effect of temperature on the concentration of Li atoms in the diamond and on the Li–O species on the surface of diamond sample. We are doping oxygen-terminated boron-doped polycrystalline diamond and nitrogen-doped High-Pressure High-Temperature (HPHT) diamond (111) with Li atoms using microwave plasma. The oxygen termination was induced by acid washing. We analyzed the sample with X-Ray Photoemission Spectroscopy (XPS) and Raman spectroscopy. The main aim of this study is to analyze the change in concentration of Li atoms in the bulk and on the surface of diamond with annealing temperature. This study can reveal an important piece of information

about the optimization of surface termination of diamond with the –O–Li group. This is crucial for developing an effective NEA diamond surface for further applications.

Materials and methods

Boron-doped polycrystalline diamond (BDD) with dimensions of 10×10 mm, 0.6 mm thickness, and HPHT Nitrogen-doped single crystal (111) with dimensions of 3×3 mm and 0.3 mm thickness were used as the substrates. The process of nitrogen and boron doping is described elsewhere [19].

The substrates were acid washed with a solution of sulphuric acid (H₂SO₄) and potassium nitrate KNO₃ to remove any metallic contaminants present on the surface, this process also terminated the surfaces with oxygen [33]. The substrates were hydrogen plasma treated in a microwave plasma at 900 °C for 2 min, followed by 2 min at 500 °C as described in [22]. This served to smoothen the diamond surface and has been proven to terminate the sample with hydrogen [34]. Lithium nitride (Li₃N), a source of Li, was obtained commercially as a powder from CERAC (99.5% purity, 250 μm particle size). It has already been established that the stability of Li₃N suspension with any oxygen-free liquid increases with an increase in polarity of that liquid, with chloroform being the best of all [19]. So, a stable suspension containing 85 mg of Lithium nitride powder suspended in a solution of 5 mg of polyoxyethylene ether (POE) in 5 ml of chloroform was prepared. It resulted in a reddish-brown suspension which was sonicated for 1 h in an ultrasonication bath.

The surface quality of both diamond substrates was analyzed with scanning electron microscopy (SEM) and Raman spectroscopy for bulk damage to the *sp*³ character or evidence of strong graphitization. The lithium nitride solution was drop cast on the surface of both substrates at a volume of 10 μl using a μ-pipette. The substrates were mounted in the NanoESCA facility and were annealed at different temperatures ranging from 500 to 850 °C under ultra-high vacuum (UHV) conditions.

XPS measurements were acquired with samples at room temperature (RT) with a monochromatic Al Kα source (1486.7 eV) in as-prepared condition and after each annealing step. A pass energy of 20 eV was used, for an overall energy resolution of 600 meV. The angle between sample and electron analyser has been set to 45°. After annealing at 750 °C and 850 °C, additional XPS measurements at more normal angle, i.e., 25°, were acquired, allowing more in-depth analysis of the sample.

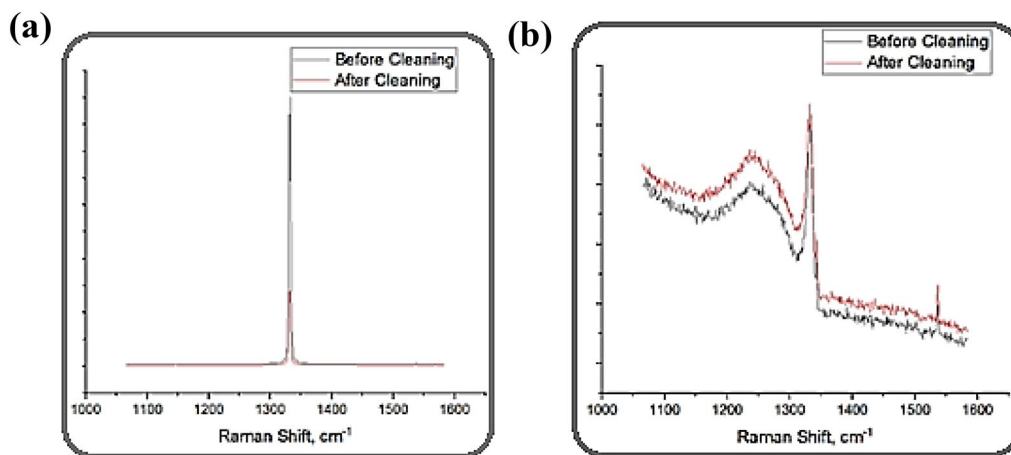


Fig. 1 **a** Raman spectra of HPHT Single crystal; **b** Raman spectra of Polycrystalline Diamond after acid washing

Results and discussion

We investigated any bulk defects and graphitization due to cleaning with Raman spectroscopy (Fig. 1a and b) using a 785 nm laser. No signs of significant graphitization or loss of sp^3 character were observed in HPHT diamond; however, there is a small peak around 1540 cm^{-1} , which corresponds to the defect clusters in BDD diamond and could not be removed with acid washing. The acid wash did not create any visible defects while getting rid of the surface impurities and graphitized portions.

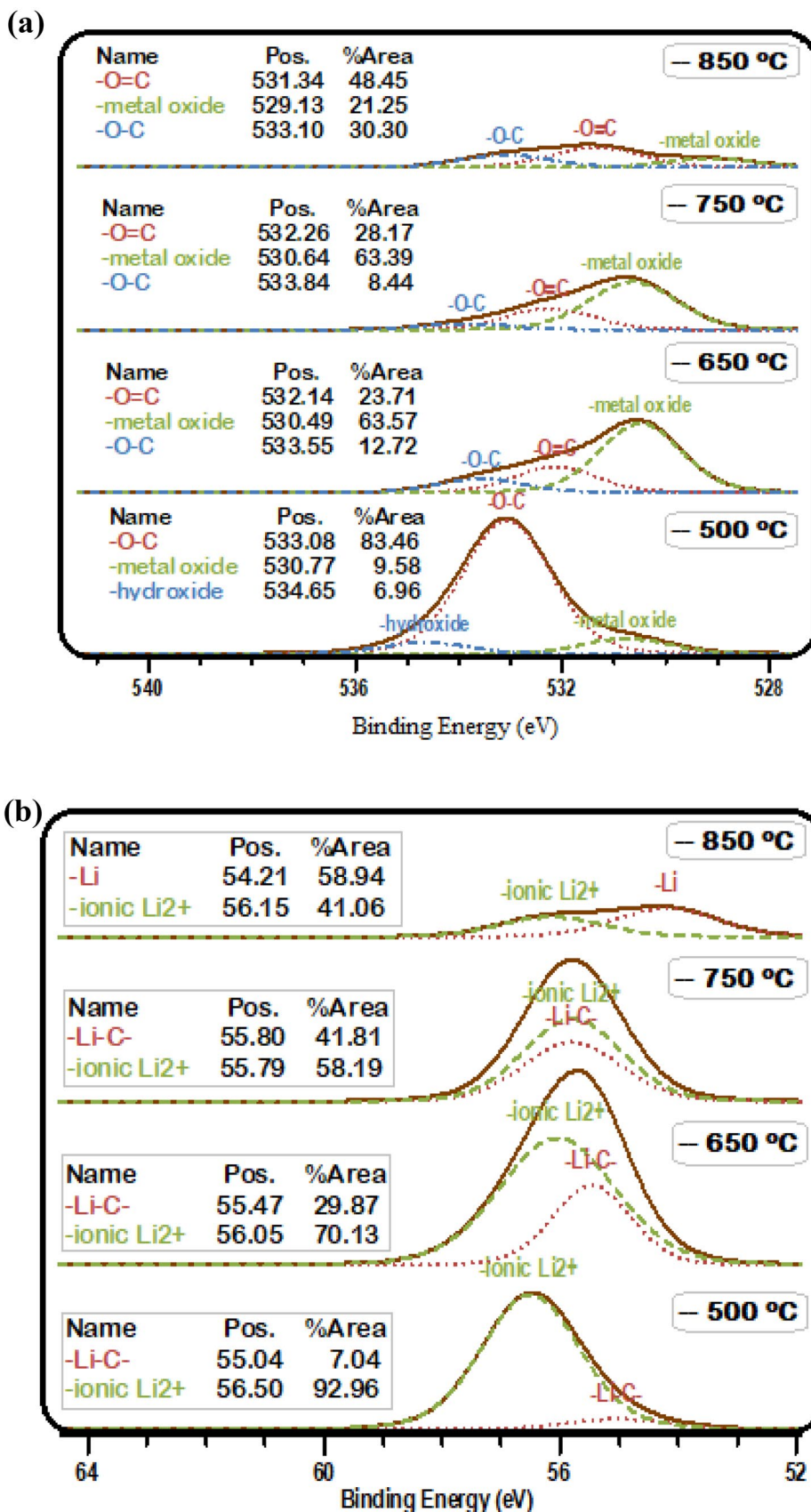
XPS gives us qualitative and quantitative information of the sample surface such as percentage composition and oxidation state of surface species. Figure 2a and b shows the O 1s and Li 1s peaks at different annealing temperatures. The deconvolution of the O 1s peaks reveals the presence of a mix of ether and carbonyl bonds, while another peak for metal oxide can be seen at a lower binding energy of 530.77 eV which can be attributed to LiO_2 [35]. At higher annealing temperatures, we see a decrease in the peak area of O 1s, indicating loss of oxygen as has been seen on many samples. The metal oxide peak increases in area at 650 °C and thereafter starts decreasing at higher temperatures. However, some of the oxygen is still retained at 850 °C which points towards the stability of oxygen-terminated diamond surface as the oxygen doesn't completely escape with metal atoms, but binds to the carbon atoms on the surface of diamond.

A similar trend can be seen in Li 1s peaks where a deconvolution of the peak reveals the presence of ionic Li^{2+} component along with another low binding energy (B.E.) peak which can be attributed to the metallic Li diffused into the near-surface bulk of diamond. However, this point cannot be proven by mere analysis of Li 1s peak. For this reason, the sample was tilted to an emission angle of 25° (to the

normal of the sample surface) where it is more bulk sensitive (BS position) as demonstrated in Fig. 3a. Figure 3b and c reveal the deconvoluted C 1s peak at the annealing temperatures of 750 °C and 850 °C with XPS emission angle of 45° (more surface sensitive) and 25° (more bulk sensitive). The peak deconvolution at 750 °C reveals the presence of a diamond peak (boron doping) at 284.6 eV [22], a peak for single bonded carbon ($-\text{C}-\text{O}-$) at 285.6 eV, and another peak around 283 eV which was attributed to the metal carbide bond [36], in this case $[-\text{Li}-\text{C}-]$. The contribution of the metal carbide peak in bulk sensitive mode was found to be 2.04% of the total peak area, while in the surface sensitive mode it was just 0.13% of the total peak area (a difference of more than 90%).

This is interesting as it can be true only if Li has diffused into the near-surface bulk of diamond. Zamir et al. have demonstrated the successful co-doping of Li-N in the diamond crystal [19] using the same chemical process of Li deposition. Hence a stable interstitial doping [9] of the substrate with Li atoms at higher annealing temperatures is demonstrated along with the formation of stable Li-O-termination of diamond surface using the chemical route. A similar trend is seen in the case of an 850 °C annealing temperature where the peak area of $-\text{M}-\text{C}-$ peak in BS mode is more than 5% than in SS mode which shows that at 850 °C the Li in the bulk positions have diffused to the surface. At 850 °C, the metal carbide peak in Fig. 3c can be seen to decrease in area. At 850 °C, however, the significant decrease in the peak areas of O 1s and Li 1s in Fig. 2a and b is seen which was attributed to not only the expulsion of Li atoms from within the near-surface bulk of diamond, but also the desorption of Li-O groups from the surface is seen. This represents the complete dissociation of $\text{C}^+(\text{O}-\text{Li})^-$, which is also further strengthened by the fact that C 1s peak also saturates towards $\sim 285\text{ eV}$ with maximum intensity.

Fig. 2 a O 1s peaks and b Li 1s peak showing deconvoluted peaks at various annealing temperatures



The O 1s peak can also be seen again shifting towards higher binding energy with decreased intensity (expulsion of O and Li from the surface) at the same temperature, a point that will be discussed later.

The discussion on the peak areas can be summarized by Fig. 4a and b in the form of the stoichiometric ratios between O:C, O:Li, and C:Li for both samples. These were calculated by normalizing the photoemission line areas by the relative sensitivity factors and plotted at different annealing temperatures from RT to 850 °C. The bar diagram shows that as the annealing temperature is increased, the Li:C ratio increases from 500 to 650 °C and then decreases slightly to 750 °C and then significantly at 850 °C both in surface and bulk sensitive modes. It can also be seen that N-doped diamond shows more stable response to higher annealing temperature than B-doped polycrystalline diamond. This could be due to many grain boundaries which can affect the incorporation and diffusion of Li into the near-surface bulk in polycrystalline diamond than in single crystal diamond. The O:C ratio has been seen to decrease with annealing temperature, while Li:O first increases and then decreases beyond 750 °C. A similar trend has been seen in case of nitrogen-doped HPHT diamond. An explanation for it will be given later.

Figure 5b shows the B.E. shift of C 1s, O 1s, and the C:O relative shift. A peak shift occurs due to the formation of surface dipole between the higher electronegative species O and the lower electronegative C atoms which result in the C+–O–dipole as demonstrated in Fig. 5a. When Li atoms interact with O it results in the transfer of more charge and hence negative potential on O atoms which leads to a lower B.E. as can be seen in the Figs. 2a and 5b where peak shifts of O have an upward trend. A similar trend can be seen in C atoms. The Li diffusion into the near-surface bulk region of diamond would increase the electric potential on the C atoms and hence a shift of C atoms towards lower B.E. (this can also be seen as an upward trend in C 1s shift in Fig. 5b). A plateau was seen in case of C 1s peak shift at the annealing temperature of 650 °C which indicates a saturation point. O atoms reach their maximum shift at 650 °C, and thereafter, the shift decreases slightly. This can be interpreted in the following way. The near-surface bulk of diamond reaches a saturation point of retaining Li atoms at 650 °C which continues through 750 °C, while the maximum interaction occurs between Li and O atoms at the surface at 650 °C indicating the formation of a sub-monolayer of LiO₂ on the surface of diamond. After 750 °C, the Li atoms start coming out of the diamond bulk and at the same time Li–O surface groups start desorbing from the surface resulting in the shift of C 1s peak towards higher B.E. (a downward trend in B.E. of C 1s). Similarly, the surface-bonded O also shifts slightly towards higher binding energy due to Li leaving the surface along with the desorbing O atoms at higher annealing temperature of 850 °C.

The shift and asymmetry in C 1s peak of diamond surface with functionalization has been attributed to the surface band bending and surface state formation. This can be calculated using Maier's approach [37]. Using the B.E. of the C1s bulk core-level component and the fixed energy separation of 283.9 ± 0.1 eV between the VBM and the C 1s core level, the VBM values at various annealing conditions were calculated as shown in Fig. 5c. CBM was calculated by adding experimental band gap value of 5.47 eV to the VBM.

There is a slight upward band bending at annealing temperature of 650 °C at which saturation of Li–O bonding and Li diffusion into near-surface diamond bulk occurs which then bends again downwards (similar to the XPS peak shift) at 850 °C due to the expulsion of Li atoms from diamond bulk and desorption of Li–O groups from the surface.

A possible explanation summarizing the results obtained could be, as diagrammatically shown in Fig. 6, that initially upon annealing at 500 °C, Li starts to break out of the solution and starts bonding with the oxygen which is present on the surface of the diamond. These are bonded as a mix of ether and carbonyl bonds to form a LiO₂ termination on the diamond surface. Some of the Li atoms enter the interstitial sites inside the near-surface diamond bulk and impart negative potential to the C atoms. As annealing temperature increases to 650 °C, the Li–O bonding reaches saturation, and we see a change in C1s peak shift and band structure changes. The stability of Li termination on the surface of diamond and Li atoms inside the diamond bulk has been established before [19, 32]. No change occurs at 750 °C until the annealing temperature is further increased to 850 °C where the Li which is mobile inside the diamond lattice [9, 19] starts diffusing and forms –O–Li groups many of which desorb at the same temperature from the surface [38]. A chemical route of creating O–Li termination on the surface of diamond and diffusion of Li atoms into the near-surface bulk was determined. This was stable up to 850 °C.

An increase in the surface conductivity can be expected with increasing Li concentration in the near-surface bulk as a shift in the valence band maximum and conduction band minimum was seen (Fig. 5c). Moreover, Li also increases the electron density near the surface of the diamond and hence changes the surface conductivity as well. This trend can be seen up to 650 °C and falls drastically at 850 °C at which point the Li has almost fully desorbed from the near-surface bulk of diamond as seen in Fig. 3c.

Lithium and lithium oxide termination of diamond has been shown to induce NEA on the surface of the diamond and hence decrease the work function (WF) significantly up to a temperature of 800 °C [32, 38]. Hence, a decrease in the WF of the diamond surface in our sample up to 750 °C is expected. Up to this temperature, O–Li bonds are stable on the diamond surface before they desorb at 850 °C.

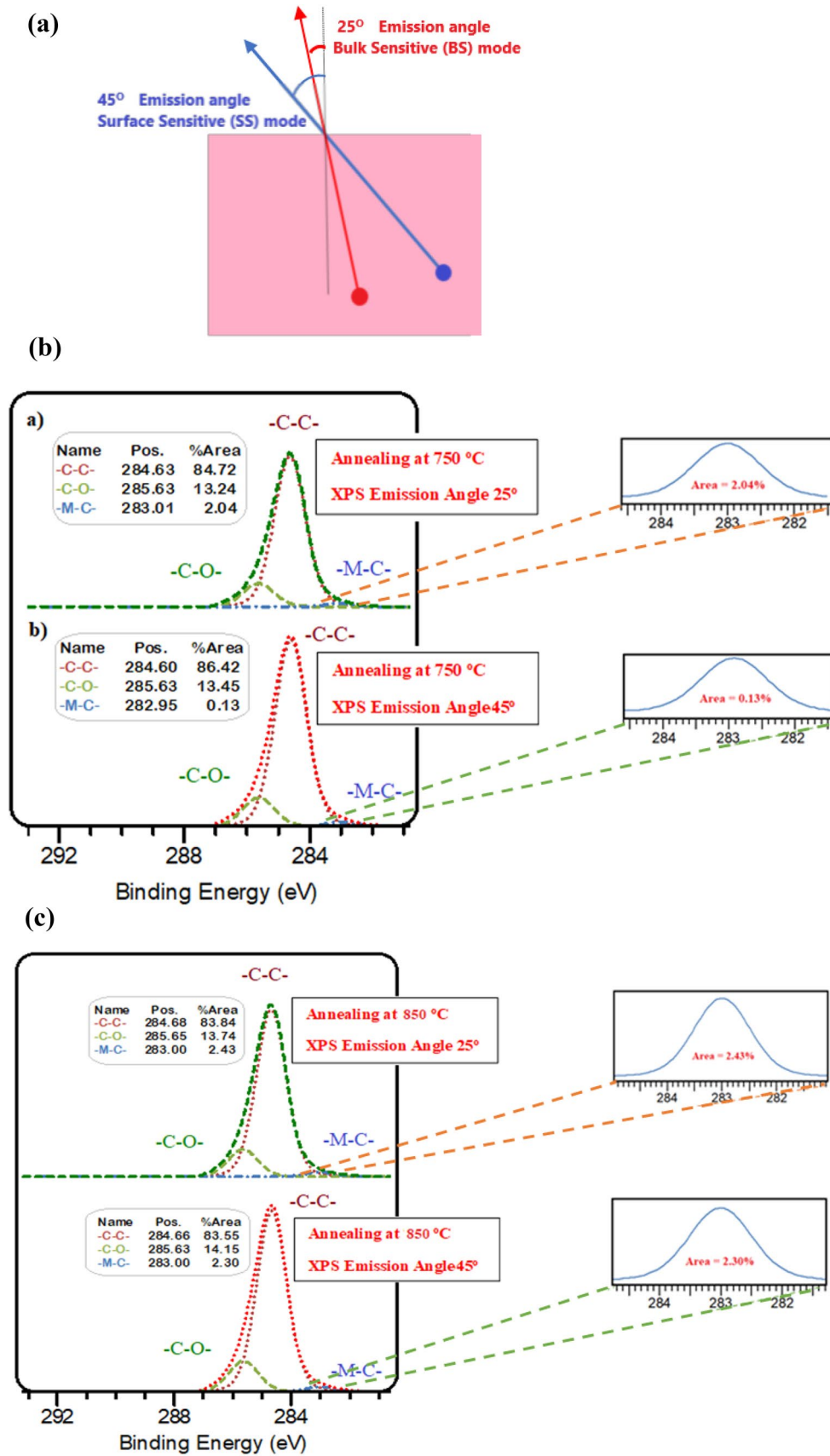


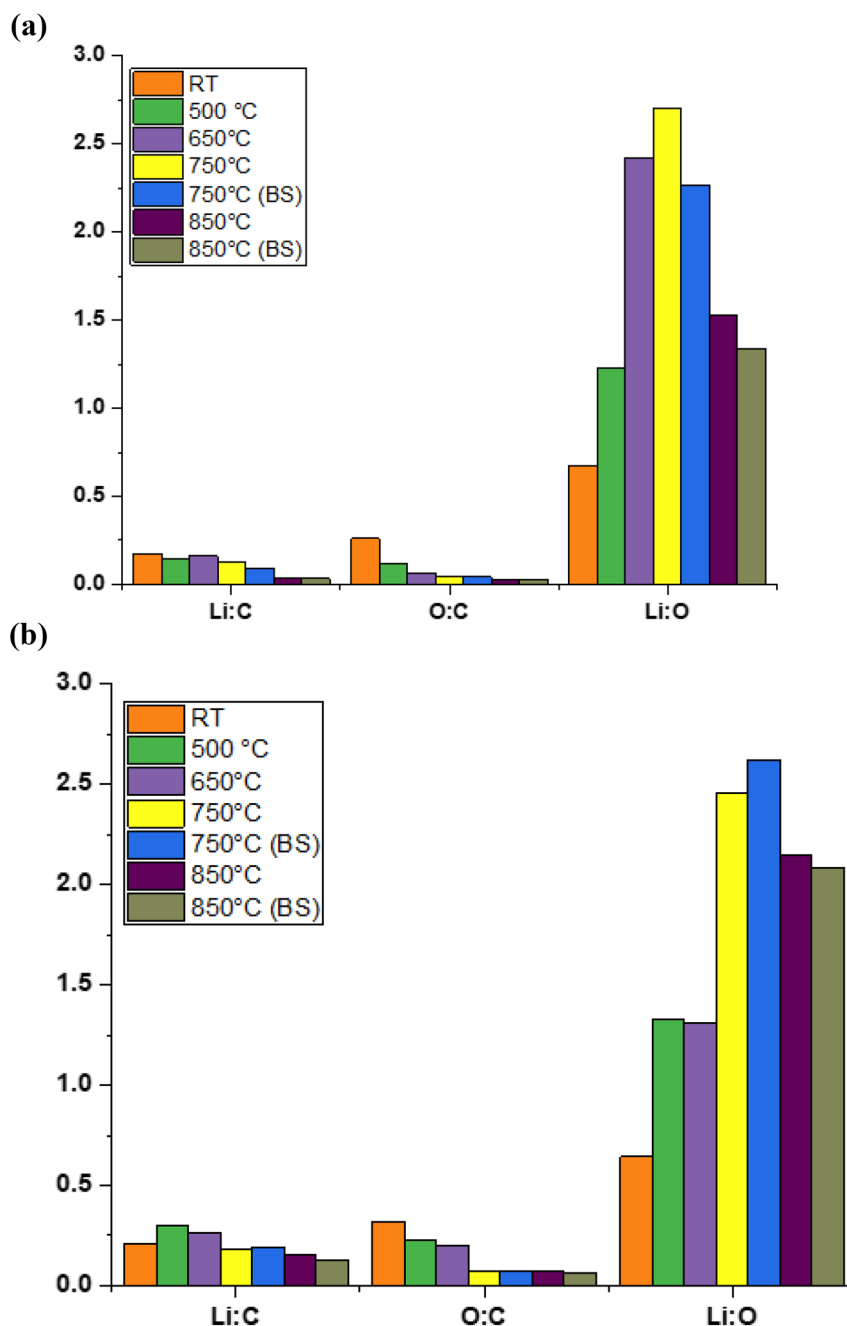
Fig. 3 **a** Angle-resolved XPS showing Bulk sensitive (BS) and surface sensitive (SS) modes at 25° and 45° to the normal of the sample. **b** Angle-resolved XPS of C1s peak in the BS mode (25°) and SS mode (45°) at 750 °C. **c** Angle-resolved XPS of C 1s peak in the BS mode (25°) and SS mode (45°) at 850 °C

Conclusion

The interaction between Li, O, and C species on the surface of diamond was visualized with increasing annealing

temperature. This is an important study to realize a metal oxide-terminated diamond surface for low work function thermionic devices. The possible intercalation of Li inside the diamond sample has also been demonstrated. The Li was shown to reach the surface of the diamond crystal as the temperature is increased to form a stable $-O-Li$ termination up to 850 °C. This is a novel and easy chemical approach of forming such terminations as previously it has been demonstrated using physical vapor deposition methods only. We have been able to prove this from the relative intensity and

Fig. 4 **a** The relative intensities of Li:C, O:C, and Li:O ratios; for Boron-Doped polycrystalline diamond. **b** relative intensities of Li:C, O:C, and Li:O ratios for Nitrogen-Doped single crystal diamond



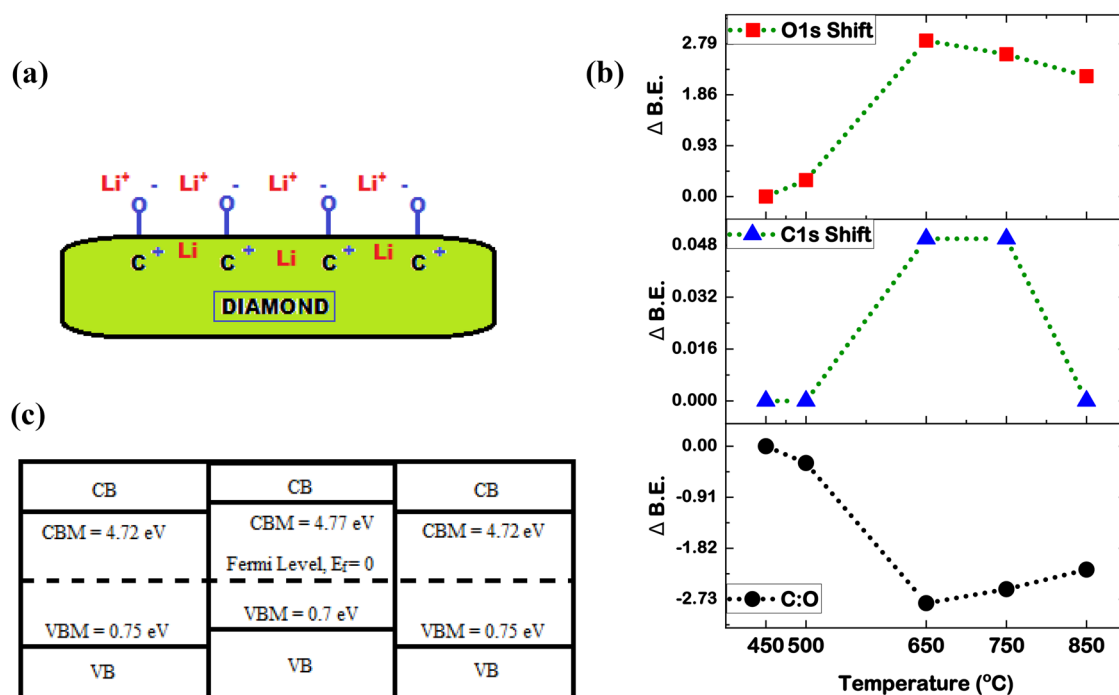


Fig. 5 **a** O–C dipole representation of the diamond surface showing the dipole between C–O due to charge transfer between the species. **b** O 1s, C 1s, and C:O relative shifts showing a saturation point at 650 °C and significant changes at 850 °C as explained. **c** The band

structure of diamond showing the position of Valence band maximum (VBM) and Conduction band Maximum (CBM) at 500 °C, 650 °C, and 850 °C

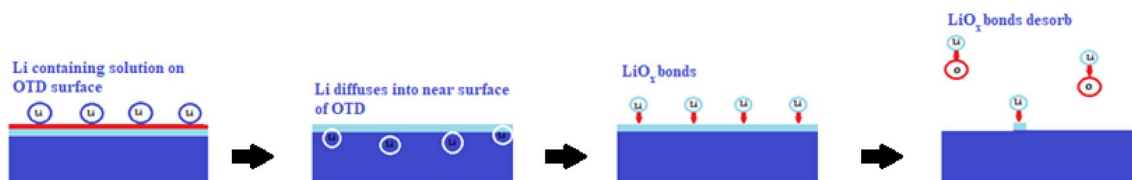


Fig. 6 The process of O–Li adsorption and Li diffusion into the near-surface diamond bulk at the initial annealing temperatures and desorption of LiO_x groups at higher annealing temperatures

shifts of XPS peaks in BDD and Nitrogen-doped HPHT single crystal samples. This work could serve as an insight into the alloy termination of diamond with alkali and other higher order metals, some of which have been predicted to lower the work function significantly.

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Author contributions The manuscript was written through contributions of all authors. All authors have given approval to the final version of the manuscript.

Data Availability The datasets generated during and/or analysed during the current study are available from the corresponding author on reasonable request.

Declarations

Conflict of interest The authors declare no competing financial interest.

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